

## Supporting Information

### Tuning the surface properties of CuO films using the precursor ageing approach for enhanced photoelectrocatalytic reactions

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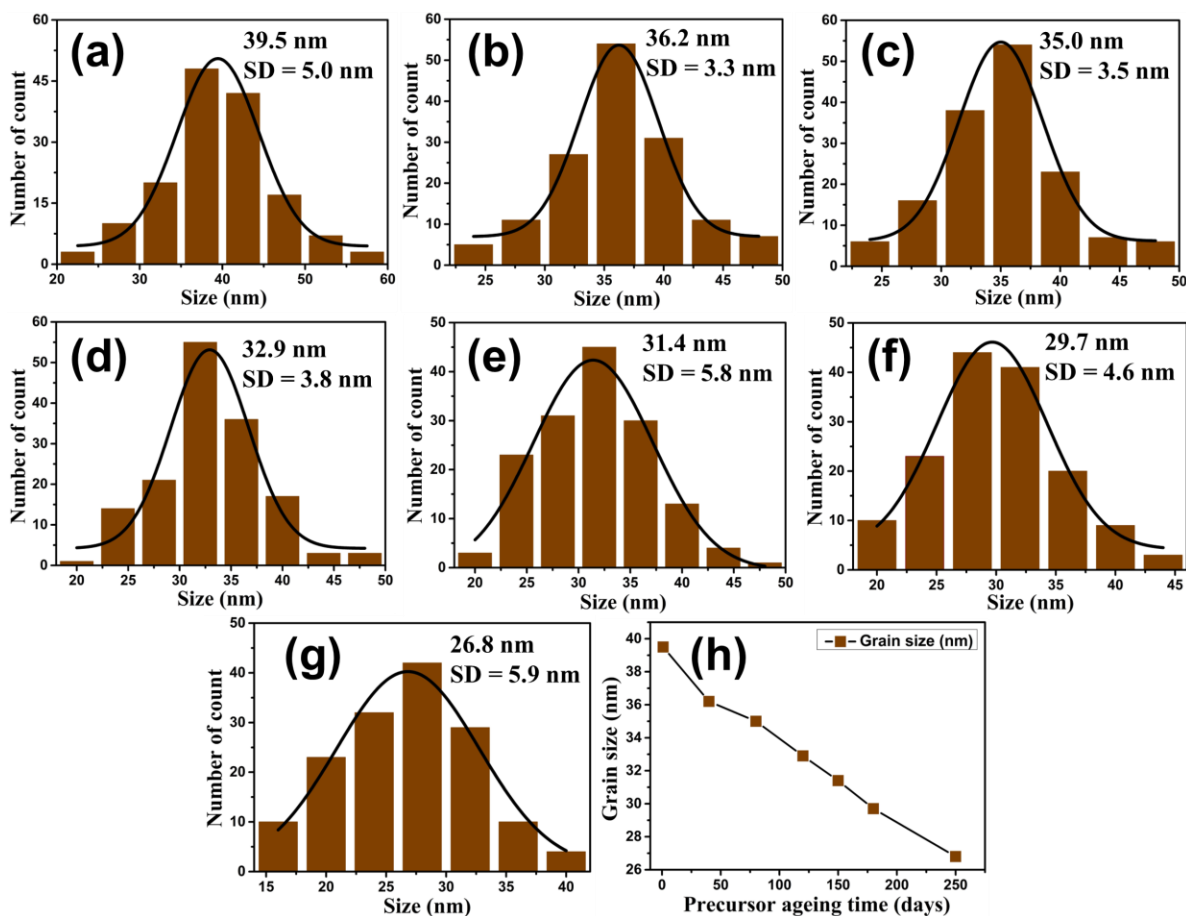


Figure S1. The histogram for the average particle diameter distribution for (a) CuO-1d, (b) CuO-40d, (c) CuO-80d, (d) CuO-120d, (e) CuO-150d, (f) CuO-180d, and (g) CuO-250d films respectively: (h) presents a plot of the grain size estimated for the films prepared using precursor solutions that were aged for 1-250 days.

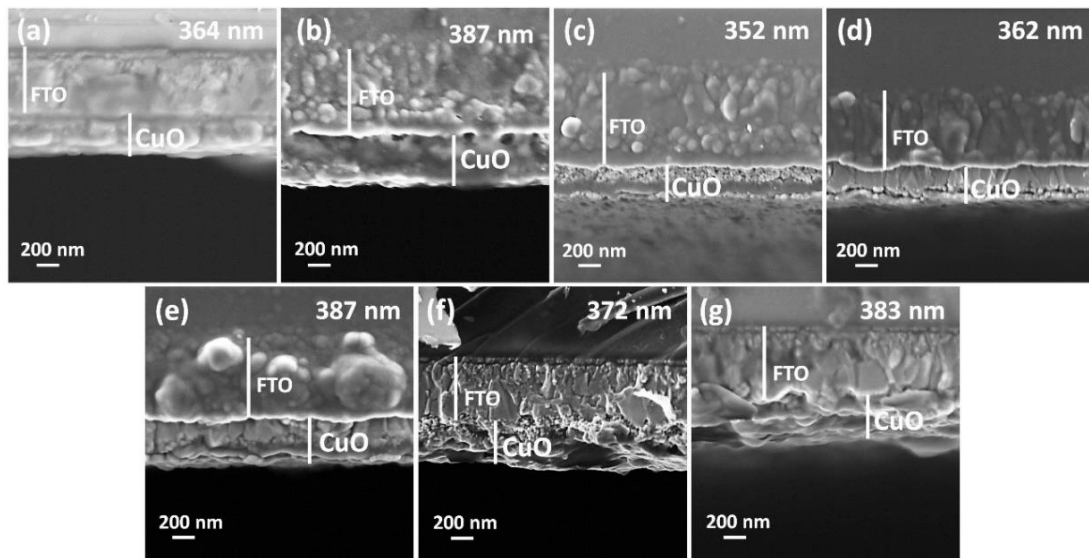


Figure S2. The cross-sectional image of (a) CuO-1d, (b) CuO-40d, (c) CuO-80d, (d) CuO-120d, (e) CuO-150d, (f) CuO-180d, and (g) CuO-250d samples.

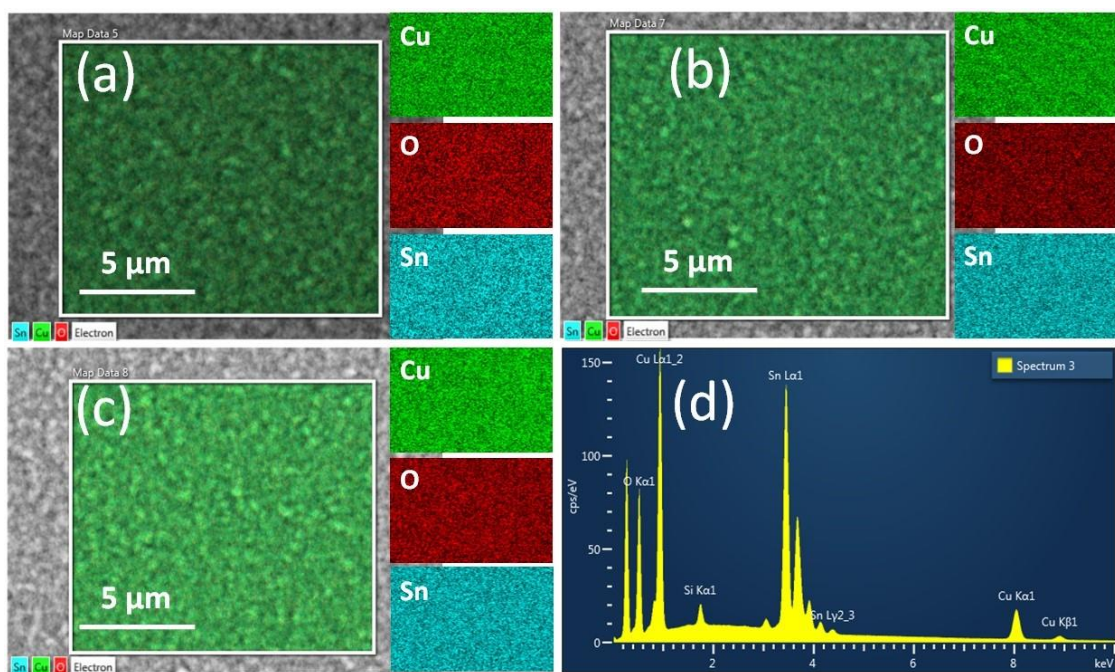


Figure S3. The EDS elemental distribution for (a) CuO-40d, (b) CuO-80d, and (c) CuO-120d samples: (d) shows the composition of the CuO-180d films after an EDS point scan.

Table S1. Direct and indirect bandgap values of dip-coated CuO films prepared using a precursor solutions that were aged for 1 to 250 days.

Sample	Indirect Bandgap (eV)	direct Bandgap (eV)
<b>CuO-1d</b>	1.34	2.29
<b>CuO-40d</b>	1.35	2.41
<b>CuO-80d</b>	1.31	2.32
<b>CuO-120d</b>	1.34	2.34
<b>CuO-150d</b>	1.27	2.27
<b>CuO-180d</b>	1.2	2.1
<b>CuO-250d</b>	1.21	2.14

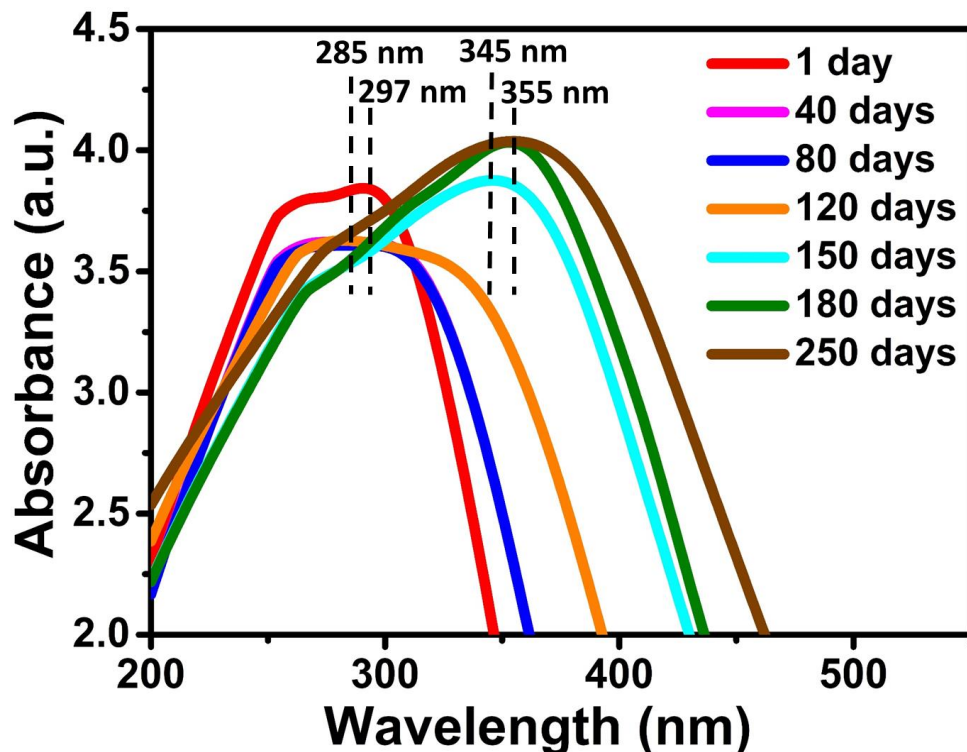


Figure S4. A magnified UV-Vis absorption spectra of copper-based solution that was aged for 1 to 250 days in the region of 200-550 nm, showing the red-shifting of the absorption peaks with precursor ageing.

Table S2. MS analysis data of dip-coated CuO photocathodes prepared using precursor solution that was aged for 1-250 days.

Sample	$N_A * 10^{20} \text{ (cm}^{-3}\text{)}$	$V_{fb}$ vs RHE (V) in 0.5M $\text{Na}_2\text{SO}_4$	$E_{VB}$ (eV)	$E_{CB}$ (eV)
CuO-1d	3.3	0.678	0.88	-0.46
CuO-40d	6.9	0.670	0.87	-0.48
CuO-80d	6.0	0.652	0.85	-0.46
CuO-120d	2.8	0.696	0.90	-0.44
CuO-150d	2.1	0.729	0.93	-0.34

<b>CuO-180</b>	8.3	0.708	0.91	-0.29
<b>CuO-250d</b>	2.1	0.703	0.90	-0.31

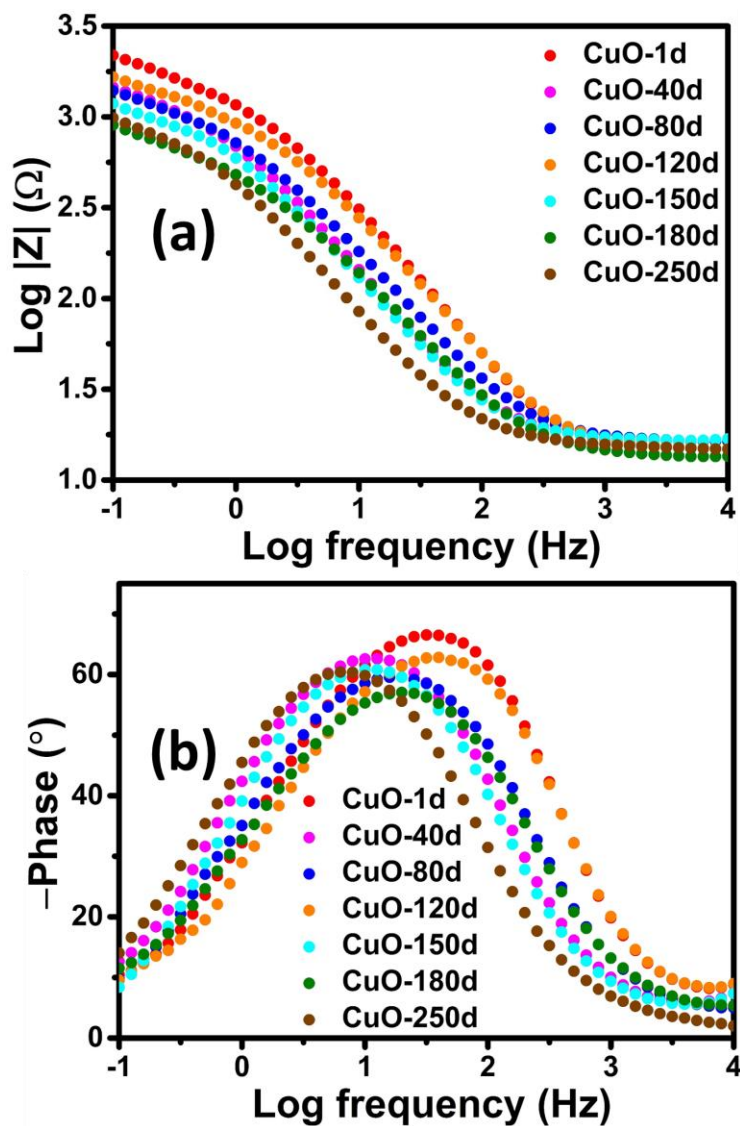


Figure S5. EIS (a) Bode plots of  $\log |Z|$  vs  $\log$  frequency, and (b) phase vs  $\log$  frequency.

Bode plots obtained for the CuO photocathodes were analyzed to further examine the charge transport properties of the samples. The graphs of  $\log |Z|$  against  $\log$  frequency are given in Figure S5 (a) for all the photocathodes. The plot revealed the minimum  $\log |Z|$  magnitude for CuO-180d samples and the highest value for CuO-1d films. A reduction in the  $\text{Log } |Z|$  value

indicates the reduction of resistance to charge transfer at the photoelectrode/liquid junction, which is essential in enhancing the catalytic response of photoelectrodes. The plots of phase angle vs log frequency are shown in Figure S5 (b) for all the CuO samples. The plots revealed the most positive peak for CuO-180d photocathodes. A more positive phase angle peak portrays evidence of a boost in charge carrier mobility at the electrode/electrolyte interface.<sup>[1]</sup>

Table S3. A comparison of the photocurrent density (J) achieved for the CuO photocathodes in this project with other reports in literature.

<b>CuO films morphology</b>	<b>Preparation method</b>	<b>Photocurrent density (J)</b>	<b>Reference</b>
CuO nanoparticles	Sol-gel dip coating	-1.6 mA/cm <sup>2</sup> at 0.35 V vs RHE, 1 M NaOH electrolyte, and under 1 sun.	This work
CuO Nanoparticles	Electrodeposition	-0.49 $\mu$ A/cm <sup>2</sup> at -0.55 V vs Ag/AgCl, 1 M KOH electrolyte, 1 sun	[2]
CuO Nanoparticles	Thermal condensation	-0.50 mA/cm <sup>2</sup> at 0 V vs RHE, 0.1 M Na <sub>2</sub> SO <sub>4</sub> electrolyte, and under 1 sun.	[3]
intermingled nanosheets	Microwave-assisted	-1.15 mA/cm <sup>2</sup> at 0 V vs RHE, 0.1 M Na <sub>2</sub> SO <sub>4</sub> electrolyte, and under 1 sun.	[4]
Nanoparticles	Electrodeposition	-1.39 mA/cm <sup>2</sup> at 0 V vs RHE, 0.1 M Na <sub>2</sub> SO <sub>4</sub> electrolyte, and under 1 sun	[5]
Nanoleaves	Sol-gel spin-coating	-0.3 mA/cm <sup>2</sup> at -0.55 V vs SCE, 1 M NaOH electrolyte, and under 1 sun	[6]
Nanoparticles	Electrodeposition	-1.1 mA/cm <sup>2</sup> at 0.1 V vs RHE, 0.2 M Na <sub>2</sub> SO <sub>4</sub> electrolyte, and under 1 sun	[7]
Nanoleaves	Aqueous solution-based	-1.5 mA/cm <sup>2</sup> at -0.6 V vs Ag/AgCl, 0.1 M Na <sub>2</sub> SO <sub>4</sub> electrolyte, and under 1 sun	[8]
Nanorods	Sol-gel spin-coating	-1.13 mA/cm <sup>2</sup> at -0.6 V vs SCE, 1 M KOH electrolyte, and under 1 sun	[9]
Nanosheets	Sol-gel spin-coating	-3.09 mA/cm <sup>2</sup> at -0.5 V vs RHE, 0.5 M Na <sub>2</sub> SO <sub>4</sub> electrolyte, and under 1 sun	[10]
Nanoparticles	Sputtering	-1.68 mA/cm <sup>2</sup> at 0 V vs RHE, 0.1 M Na <sub>2</sub> SO <sub>4</sub> electrolyte, and under 1 sun.	[11]
hollow spheres	doctor-blade	-1.47 mA/cm <sup>2</sup> at -0.3 V vs Ag/AgCl, 0.5 M Na <sub>2</sub> SO <sub>4</sub> electrolyte, and under 1 sun	[12]

## References

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